

**M.Sc. ELECTRONICS**  
**First Semester**  
**SEMICONDUCTOR MATERIALS AND DEVICES**  
**(MSE - 103)**

**Duration: 3Hrs.**

**Full Marks: 70**

Part-A (Objective) =20  
Part-B (Descriptive) =50

**(PART-B: Descriptive)**

**Duration: 2 hrs. 40 mins.**

**Marks: 50**

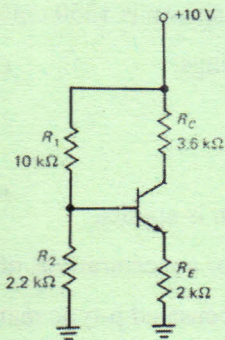
**Answer any four from Question no. 2 to 8**  
**Question no. 1 is compulsory.**

1. Consider a sample of silicon at 300K doped at an impurity concentration of  $N_d=10^{15}\text{cm}^{-3}$  and  $N_a=10^{14}\text{cm}^{-3}$ . Electron mobility in silicon is  $1350\text{cm}^2/\text{V-sec}$  and hole mobility is  $480\text{cm}^2/\text{V-sec}$ . Find out the followings: (3+3+4=10)
  - a. Thermal equilibrium concentration of electrons
  - b. Thermal equilibrium concentration of holes
  - c. Drift current density if an electric field of  $35\text{V/cm}$  is applied.
2. A silicon semiconductor is initially doped with donor concentrations of  $N_d=5\times 10^{15}\text{cm}^{-3}$ . Acceptor is to be added to form a compensated p-type materials. The sample should have resistance of  $10\text{k}\Omega$  and should be able to handle a current density of  $50\text{A/cm}^2$  when 5 volts is applied across the sample. Find out the acceptor doping concentration to achieve this specification. Limit the electric field to  $100\text{V/cm}$ . (10)
3. Consider a PN junction at 300K with acceptor doping concentration  $N_a=10^{18}\text{cm}^{-3}$  and donor doping concentration  $N_d=10^{15}\text{cm}^{-3}$ . Find out the built in potential barrier for (5+5=10)
  - a. Silicon PN junction
  - b. Gallium Arsenide PN junction

Intrinsic carrier concentration for silicon is  $1.5 \times 10^{10} \text{ cm}^{-3}$  and that for gallium arsenide is  $1.8 \times 10^6 \text{ cm}^{-3}$ .

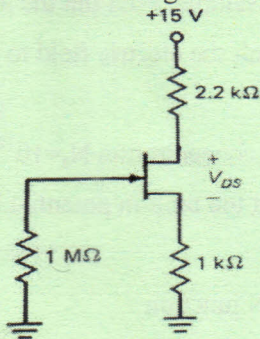
4.

- a. Draw the circuit diagram of a positive clamper circuit using a diode and explain its operation. Draw the input and output voltage waveforms also. (2+3+2=7)
  - b. Draw the circuit diagram of a negative clamper (3)
5. Explain in detail the Schmitt trigger and its application with suitable diagrams. (10)
6. In the circuit shown below find out the followings: (3+3+4=10)
- a. Base voltage
  - b. Emitter current
  - c. Collector emitter voltage.



7.

- a. In the following circuit if the drain current is 3mA find out the followings:



- i. Gate to source voltage.
  - ii. Drain voltage.
  - iii. Drain to source voltage. (3+2+2=7)
- b. What do you mean by device transconductance parameter and process transconductance parameter in a MOSFET? (3)
8. Derive the close loop gain of operational amplifier circuit using a voltage series feedback. (10)

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**Duration: 20 minutes**

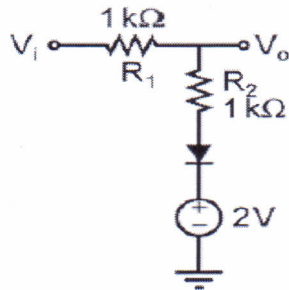
**Marks – 20**

**(PART A - Objective Type)**

**I. Choose the correct answer:**

**1×20=20**

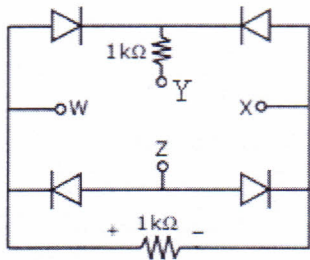
1. The diode in the circuit shown in Figure 1 has  $V_{on} = 0.7V$  but is ideal otherwise. If  $V_i = 5\sin(\omega t)$  Volts, the minimum and maximum values of  $V_o$  (in Volts) are, respectively,
- a. -5 and 2.7                      b. 2.7 and 5  
b. -5 and 3.85                    d. 1.3 and 5



2. Avalanche breakdown in a diode occurs when
- a. Potential barrier is reduced to zero.  
b. Forward current exceeds certain value.  
c. Reverse bias exceeds a certain value.  
d. None of these
3. A forward potential of 10V is applied to a Si diode. A resistance of 1 KΩ is also in series with the diode. The current is
- a. 10 mA                      b. 0.7 mA                      c. 9.3 mA                      d. 0
4. If the doping level in a ordinary PN junction diode is increased, the width of depletion layer.....
- a. remains the same                      b. decreases  
c. Increases                                      d. none of the above
5. The PIV rating of each diode in a bridge rectifier is .....that of the equivalent centre-tap rectifier
- a. one-half                                      b. the same as  
c. twice    d. four times
6. A half-wave rectifier has an input voltage of 240 V r.m.s. If the step-down transformer has a turn ratio of 8:1, what is the peak load voltage? Ignore diode drop.
- a. 27.5                                      b. 86.5 V                                      c. 30 V                                      d. 42.5 V

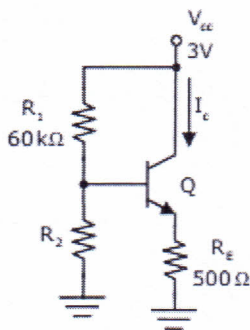
7. The use of negative feedback .....
  - a. reduces the voltage gain of an Op-amp
  - b. makes the Op-amp oscillate
  - c. makes linear operation possible
  - d. both (a) and (c)
8. The effective channel length of a MOSFET in saturation decreases with increase in
  - a. increase in source doping concentration
  - b. drain to source voltage
  - c. the gate oxide thickness
  - d. the channel length
9. A Zener diode, when used in voltage stabilization circuits, is biased in
  - a. Reverse bias region below the breakdown voltage
  - b. Reverse breakdown region
  - c. Forward bias region
  - d. Forward bias constant current mode
10. A silicon PN junction is forward biased with a constant current at room temperature. When the temperature is increased,
  - a. The forward bias voltage across the PN junction Increases.
  - b. The forward bias voltage across the PN junction Decreases.
  - c. Current through the PN junction increases due to increase in minority carrier
  - d. None of the above.
11. For a BJT the common base current gain  $\alpha = 0.98$ . This BJT is connected in the common emitter mode and operated in the active region with a base drive current  $I_B = 10\text{mA}$ . The collector current  $I_C$  for this mode of operation is
  - a. 0.49A
  - b. 0.99A
  - c. 0.98A
  - d. 1.01A
12. The intrinsic Fermi energy level in silicon does not lie exactly at the midgap energy because,
  - a. Effective mass of electron and hole are different
  - b. Effective density of states function of electron and hole are different
  - c. Silicon is an indirect band gap semiconductor
  - d. Both (a) and (b)
13. In a silicon sample Fermi energy is 0.25eV below conduction band. The effective density of states function in the conduction band at room temperature is  $2.8 \times 10^{19} \text{ cm}^{-3}$ . The probability that a state in conduction band is occupied by an electron is
  - a.  $10^{-6}$
  - b.  $6.43 \times 10^{-5}$
  - c. .05
  - d. 0.9

14. A voltage  $1000\sin\omega t$  Volts is applied across YZ. Assuming ideal diodes, the voltage measured across WX in Volts, is



- a.  $\sin \omega t$                       b.  $(\sin t \sin t / 2 \omega + \omega)$   
 c.  $(\sin t \sin t / 2 \omega - \omega)$       d. 0 for all values of t

15. In the circuit shown below, the silicon npn transistor Q has a very high value of  $\beta$ . The minimum required value of  $R_2$  should be greater than \_\_\_\_\_  $k\Omega$  to produce  $I_C = 1\text{mA}$  is



- a. 20                      b. 30                      c. 40                      d. 25

16. What should be the value of input resistance for an ideal voltage amplifier circuit?

- a. Zero                      b. Unity                      c. Infinity                      d. Unpredictable

17. What is the phase-shift between input and output voltages of CE amplifier?

- a.  $90^\circ$                       b.  $120^\circ$                       c.  $180^\circ$                       d.  $270^\circ$

18. Generally, the resistance of thermistor decreases

- a. Linearly with an increase in temperature  
 b. Linearly with the decrease in temperature  
 c. Exponentially with an increase in temperature  
 d. Exponentially with the decrease in temperature

19. The  $n^-$  region in a vertical cross-section of a typical n-p-n bipolar power transistor is also known as

- a. Emitter drift region                      b. Base drift region  
 c. Collector drift region                      d. None of the above

20. Multivibrators belong to the category of

- a. Square wave oscillators                      b. Triangular wave oscillators  
 c. Ramp wave oscillators                      d. Sinusoidal oscillators

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